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Electronic Supplementary Information

Smart functional polymer coatings for paper with anti-fouling properties

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S1 NMR of synthesized polymers



¹H NMR PMOXA-co-GMA



¹H NMR MPC-co-GMA





S2 Additional AFM-images of TMSC@SiO₂ and cellulose@SiO₂



Fig. S 1 AFM-image of TMSC@SiO2 prepared by spin coating of a TMSC-CHCl₃ solution.



 $\label{eq:Fig.S2} \mbox{ Fig.S2} \mbox{ AFM-image of cellulose@SiO2 prepared by spin coating of a TMSC-CHCl_3 solution.}$

S3 Swelling behaviour of PMOXA-co-GMA and MPC-co-GMA grafted on cellulose as well as SiO₂



Fig. S 3 Determination of degree of swelling of the investigated polymers MPC-*co*-GMA and PMOXA-*co*-GMA grafted on cellulose@SiO₂ as well as on pure SiO₂ by in-situ ellipsometry using a phosphate puffer with pH 5 and c=0.01 mol L⁻¹.

S4 XPS-measurements of PMOXA-co-GMA (2) and MPC-co-GMA (3) grafted on SiO₂, cellulose@SiO₂ as well as on filter paper



Fig. S 4 Wide-scan spectrum of (2)@SiO₂.



Fig. S 5 S 2p region of the XPS measurement of (2)@SiO₂.



Fig. S 6 Wide-scan spectrum of (3)@SiO₂.



Fig. S 7 Wide-scan spectrum of (2)@cellulose@SiO₂.



Fig. S 8 S 2p region of the XPS measurement of (2)@cellulose@SiO₂.



Fig. S 9 Wide-scan spectrum of (3)@cellulose@SiO₂.



Fig. S 10 Wide-scan spectrum of the used filter paper.



Fig. S 11 Wide-scan spectrum of (2)@filter.



Fig. S 12 Wide-scan spectrum of (3)@filter.

S5 pH-stability of polymer coatings



Fig. S 13 Investigation of pH-stability of PMOXA-*co*-GMA on SiO₂ and on cellulose@SiO₂ as well as MPC-*co*-GMA on SiO₂ and cellulose@SiO₂ direct after one, two and 16 hours.